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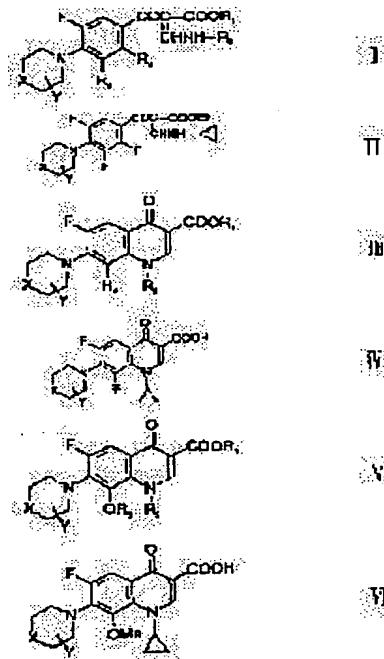
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(54) PRODUCTION OF QUINOLONECARBOXYLIC ACID DERIVATIVE AND ITS SYNTHETIC INTERMEDIATE

(57)Abstract:

PURPOSE: To obtain a 6-fluoro-7-substituted-3-quinolonecarboxylic acid useful as an antimicrobial agent (medicine) or its intermediate in relatively high yield from a new substance without producing toxic substances with industrial advantages even to cost.

CONSTITUTION: A compound expressed by formula I [R1 is H or lower alkyl; R2 is lower alkyl or lower cycloalkyl; R3 is halogen, RSO₃, OH or esters thereof ; R is lower alkyl, aryl or substituted aryl; R4 is H or halogen; X is (CH₂)_n, N or O; (n) is 0 or 1; Y is NH₂, lower alkylamino, group readily convertible into them by a chemical means or H], especially a new substance expressed by formula II is thermally condensed in an aprotic polar solvent to afford a compound expressed by formula III, especially a compound expressed by formula IV, which is then reacted with a compound expressed by the formula R₅ONa (R₅ is lower alkyl, especially methyl) and, as desired, subsequently hydrolyzed to industrially and advantageously provide the objective compound expressed by formula V, especially formula VI.



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